Modeling Non-Uniform UE Distributions in Downlink Cellular Networks

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Abstract—A recent way to model and analyze downlink cellular networks is by using random spatial models. Assuming user equipment (UE) distribution to be uniform, the analysis is performed at a typical UE located at the origin. While this method of sampling UEs provides statistics averaged over the UE locations, it is not possible to sample cell interior and cell edge UEs separately. This complicates the problem of analyzing deployment scenarios involving non-uniform distribution of UEs, especially when the locations of the UEs and the base stations (BSs) are dependent. To facilitate this separation, we propose a new tractable method of sampling UEs by *conditionally thinning* the BS point process and show that the resulting framework can be used as a tractable generative model to study cellular networks with non-uniform UE distribution.

I. INTRODUCTION

A promising new way to model cellular networks is by using random spatial models, where the BS locations are assumed to form a realization of some spatial point process, typically the Poisson Point Process (PPP). Modeling the UE locations as an independent PPP, the downlink analysis is performed at a typical UE assumed to be located at the origin. Owing to its tractability, this model leads to simple closed form expressions for key metrics such as coverage and average rate over the entire network [1]–[3]. Although it provides a way to study average statistics over the complete network, it does not provide any handle on studying the performance of cell edge and cell interior UEs separately. Consequently, it is not possible to model deployment scenarios involving non-uniform UE distribution, especially when the UE and BS locations are dependent. Naturally, such flexibility is desirable, especially to study the current capacity-centric deployments where BSs are specifically deployed to be proximate to areas of high UE density. The most popular and perhaps the only available option to handle such scenarios is through detailed system level simulations, which are both time consuming and have to be focused on a limited range of system parameters [4], [5].

As a first step towards a tractable model, we propose a slight modification in the way UEs are sampled by introducing the idea of *conditional thinning*. Starting with a higher density of BSs, we first assume that a typical UE is located at the origin. After selecting the serving BS, we condition on this active link and independently thin the rest of the BS point process so that the resulting density matches the desired density of the actual BSs. The thinning operation pushes the typical UE in the cell interior relative to the new cell edge defined by the resulting point process. The bias induced in the location of a typical UE towards its serving BS can be tuned by varying the thinning probability. We make this notion precise by deriving the distribution of the ratio of the distances of the UE to its serving BS and the dominant interferer as a function of the thinning probability. We also show that this framework can be used as a tractable generative model to study non-uniform UE distributions where the UEs are more likely to lie closer to the BS. The exact analysis of such non-uniform UE distributions is in general hard due to the correlation present in the UE and BS locations. The impact of the proposed model on the cellular performance analysis and its key differences from the existing model based on uniform UE distribution are highlighted in terms of the coverage predictions.

It is worth noting that although this work is developed in the context of cellular networks, it applies to much wider class of point process problems involving dependence in the location of the observation point and the point process.

II. PROPOSED METHOD OF SAMPLING UES

We consider a homogeneous PPP Φ of density λ , a thinned version of which will eventually model the BS locations. The downlink analysis is performed at a typical UE assumed to be at the origin [6]. The received power at a typical UE from the BS located at $x \in \Phi$ is

$$P_x = Ph_x \|x\|^{-\alpha},\tag{1}$$

where P is the transmit power, $h_x \sim \exp(1)$ models channel power distribution under Rayleigh fading and $||x||^{-\alpha}$ models standard distance based path loss with $\alpha > 2$ being the path loss exponent. More general fading distributions can be studied using tools developed in [7], [8]. For simplicity of exposition, we will ignore thermal noise in this discussion.

The proposed method of sampling the interior UEs can be understood in two simple steps shown in Fig. 1. The first step is to identify the serving BS in Φ for a typical UE depending upon the cell association technique being considered. While the proposed method is general, for brevity we consider nearest-neighbor cell association model discussed in [1], where each UE connects to its nearest BS. It is also the same as maximum average power connectivity model, where each UE connects to the BS that provides maximum long-term average received power. In Fig. 1 (left), the typical UE connects to its nearest BS, which is the one that corresponds to the Voronoi cell in which it lies. Denote the location of this serving BS by $x_s \in \Phi$. The second step is to independently thin the point

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Fig. 1. (left) The Voronoi tessellation of the point process Φ . Dark triangle denotes a typical UE. (middle) The point process thinned by p = .3. The remaining points form BS point process Φ_b . (right) The Voronoi tessellation of Φ_b . Observe that the typical point is now in the cell interior.

process $\Phi \setminus x_s$ where each point is independently retained with probability p as shown in Fig. 1 (middle). Since the thinning is conditional on the serving BS, we call it *conditional thinning*. The thinned process Φ_b models the BS locations. Due to conditional thinning, the point process Φ_b is no longer a PPP. After tessellating the space based on Φ_b and keeping the position of the UE fixed, we note that the UE is pushed towards the cell interior compared to the new cell edge as shown in Fig. 1 (right). As discussed in the next section, a typical UE can be pushed arbitrarily close to its serving BS by choosing an arbitrarily small value of p but remains edge biased for high values of p.

III. IMPACT ON CELLULAR NETWORKS

After providing an overview of the new UE sampling model, we now formalize the effect of conditional thinning perceived by a typical UE. Denoting R_1 and R_2 to be the distances of the closest and the next closest point of Φ_b to the origin, we define our first metric to be $R = R_2/R_1$. It corresponds to the ratio of the distances of a typical UE to its serving BS and the dominant interferer, and provides some insights into the expected performance of a typical UE. For instance, if the value of R is close to 1, it means that the UE is near the cell edge, i.e., the dominant interferer is approximately at the same distance as the serving BS and hence the received signal-tointerference-ratio (SIR) is expected to be low. It is important to note that $R \ge 1$ by construction, since the serving BS is always the closest one in our cell association model. We now derive the distribution of R after deriving the joint distribution of R_1 and R_2 as a function of thinning probability p in the following Lemma. Interested readers can refer to [9] for the marginal distribution of R_n .

Lemma 1. The cumulative distribution function (CDF) of R is

$$F_R(r) = 1 - \frac{1}{1 + p(r^2 - 1)}, \ r \ge 1.$$
 (2)

Proof: For notational simplicity, we first define the following disjoint sets:

$$\mathcal{E}_1 = \{ x \in \mathbb{R}^2 : \|x\| \le r_1 \}$$

$$\mathcal{E}_{2} = \{ x \in \mathbb{R}^{2} : r_{1} < \|x\| \le r_{1} + dr_{1} \}$$

$$\mathcal{E}_{3} = \{ x \in \mathbb{R}^{2} : r_{1} + dr_{1} < \|x\| \le r_{2} \}$$

$$\mathcal{E}_{4} = \{ x \in \mathbb{R}^{2} : r_{2} < \|x\| \le r_{2} + dr_{2} \}$$

where \mathcal{E}_1 denotes a circle centered at origin and the rest denote annular regions defined by concentric circles centered at the origin. Further let $N(\mathcal{E})$ be a random counting measure of a Borel set \mathcal{E} , i.e., $N(\mathcal{E}) = \#$ of points in \mathcal{E} . Now to derive the CDF of R, we first derive the joint probability density function (PDF) of R_1 and R_2 , which by definition can be expressed as

$$f_{R_1,R_2}(r_1,r_2) = \lim_{\substack{\mathrm{d}r_1 \to 0 \\ \mathrm{d}r_2 \to 0}} \frac{\mathbb{P}\left(R_1 \in \mathcal{E}_2, R_2 \in \mathcal{E}_4\right)}{\mathrm{d}r_1 \mathrm{d}r_2}.$$
 (3)

The numerator of the above expression can be expressed as:

$$\mathbb{P}(R_1 \in \mathcal{E}_2, R_2 \in \mathcal{E}_4) = \\
\mathbb{P}(N(\mathcal{E}_1) = 0, N(\mathcal{E}_2) = 1, N(\mathcal{E}_3) = 0, N(\mathcal{E}_4) = 1) = (4) \\
\mathbb{P}(N(\mathcal{E}_1) = 0) \mathbb{P}(N(\mathcal{E}_2) = 1) \mathbb{P}(N(\mathcal{E}_3) = 0) \mathbb{P}(N(\mathcal{E}_4) = 1),$$

where the simplification follows from the fact that the sets \mathcal{E}_i are disjoint. Now recall that the point process Φ is independently thinned by probability p outside the circle of radius $r_1 + dr_1$. Therefore, the above expression can be written as:

$$\mathbb{P}\left(R_{1} \in \mathcal{E}_{2}, R_{2} \in \mathcal{E}_{4}\right) = e^{-\lambda \pi r_{1}^{2}} \\\lambda \pi \left[\left(r_{1} + \mathrm{d}r_{1}\right)^{2} - r_{1}^{2}\right] e^{-\lambda \pi \left[\left(r_{1} + \mathrm{d}r_{1}\right)^{2} - r_{1}^{2}\right]} e^{-p\lambda \pi \left[r_{2}^{2} - \left(r_{1} + \mathrm{d}r_{1}\right)^{2}\right]} \\p\lambda \pi \left[\left(r_{2} + \mathrm{d}r_{2}\right)^{2} - r_{2}^{2}\right] e^{-p\lambda \pi \left[\left(r_{2} + \mathrm{d}r_{2}\right)^{2} - r_{2}^{2}\right]},\tag{5}$$

which for vanishingly small dr_1 and dr_2 can be simplified to:

$$p(2\pi\lambda)^2 r_1 r_2 \exp\left(-\lambda\pi r_1^2(1-p)\right) \exp\left(-p\lambda\pi r_2^2\right) \mathrm{d}r_1 \mathrm{d}r_2,$$
(6)

from which the joint PDF of R_1 and R_2 can be expressed as:

$$f_{R_1,R_2}(r_1,r_2) = p(2\pi\lambda)^2 r_1 r_2 e^{-\lambda\pi r_1^2(1-p)} e^{-p\lambda\pi r_2^2},$$
 (7)

for $r_2 \ge r_1 \ge 0$. Using this joint density, the CCDF of R can now be expressed as:

$$\mathbb{P}[R > r] = \mathbb{P}\left[\frac{R_2}{R_1} > r\right] \tag{8}$$



Fig. 2. The CDF of R for various values of conditional thinning probability p. The theoretical results are overlaid with dotted plots of the simulation results showing perfect match.

$$= \int_{r_2=0}^{\infty} \int_{r_1=0}^{\frac{r_2}{r}} f_{R_1,R_2}(r_1,r_2) \mathrm{d}r_1 \mathrm{d}r_2 = \frac{1}{1+p(r^2-1)}, \quad (9)$$

which completes the proof.

Recall that for p = 1 the proposed model reduces to the uniform distribution of UEs, leading to the following corollary.

Corollary 1. The CDF of R for the typical observation point that is defined to be uniformly distributed in \mathbb{R}^2 independent of the BS locations (p = 1 in the proposed model) is

$$F_R(r) = 1 - \frac{1}{r^2}, \ r \ge 1.$$
 (10)

Corollary 2. The mean value of R as a function of p is

$$\mathbb{E}[R] = 1 + \frac{1}{\sqrt{p(1-p)}} \left(\frac{\pi}{2} - \tan^{-1}\left(\frac{\sqrt{p}}{\sqrt{1-p}}\right)\right), \quad (11)$$

which for p = 1 is $\mathbb{E}[R] = 2$.

Remark 1 (Dependence in UE and BS point processes). *The level of dependence induced in the locations of the UEs and the BSs is inversely proportional to the thinning probability p, i.e., the probability of finding a typical UE in the cell interior close to its serving BS is higher for smaller values of p. This is evident from the mean of R given by Corollary 2 and from the plot of the CDFs of R for various values of p in Fig. 2.*

We now derive the coverage probability of a typical UE sampled under the new proposed method. The coverage probability P_c denotes the average fraction of UEs in coverage and can be formally defined as the CCDF of SIR as follows:

$$\mathbf{P}_{\mathsf{c}} = \mathbb{P}\left(\mathtt{SIR} > \beta\right) = \mathbb{P}\left(\frac{h_{x_s} \|x_s\|^{-\alpha}}{\sum_{y \in \Phi_b \setminus x_s} h_y \|y\|^{-\alpha}} > \beta\right), \quad (12)$$

where the serving BS is assumed to be located at x_s . Using tools developed in [1], a simple expression can be derived for the coverage probability of a typical UE under the proposed sampling method. The main result is given in the following Lemma along with a brief proof sketch. **Lemma 2.** The coverage probability of a typical UE when it connects to its nearest BS under the proposed UE sampling method with thinning probability p is

$$\mathsf{P}_{\mathsf{c}}(\alpha,\beta,p) = \left[1 + p\beta^{\frac{2}{\alpha}} \int_{\beta^{-\frac{2}{\alpha}}}^{\infty} \frac{1}{1 + u^{\frac{\alpha}{2}}} \mathrm{d}u\right]^{-1},\qquad(13)$$

which for $\alpha = 4$ simplifies to

$$\mathsf{P}_{\mathsf{c}}(4,\beta,p) = \left[1 + p\beta^{\frac{1}{2}} \left(\pi/2 - \arctan(\beta^{-\frac{1}{2}})\right)\right]^{-1}.$$
 (14)

This result directly follows from Theorem 2 of [1] with a slight modification to incorporate conditional thinning of the point process Φ . The coverage probability is first conditioned on the distance of a typical UE to its serving BS, which can be computed by the null probability of a PPP. Conditioned on this distance, say u, the interference field defined over $\mathbb{R}^2 \cap B(0, u)^c$ is a PPP with density $p\lambda$, where B(0, u) is a ball with radius u centered at 0 and p appears due to conditional thinning. This is the step where the proof of the current Lemma differs from that of Theorem 2 of [1]. The remaining proof, which mainly involves the derivation of the Laplace transform of interference, remains the same.

Remark 2 (Scale invariance and effect of p on P_c). For any given value of thinning probability p, the coverage probability is independent of the density of the BSs in an interference limited cellular network. This scale invariance result is a generalization of a similar observation reported in [1] for the uniform distribution of the UEs, which is a special case of the proposed model and corresponds to p = 1. As expected, the coverage probability is a monotonically decreasing function of p. This is consistent with the observations reported in [10], where a similar parametrization was used to model load on various classes of BSs in a heterogeneous cellular network.



Fig. 3. A realization of the proposed non-uniform UE distribution model.

IV. NON-UNIFORM UE DISTRIBUTION

In this section, we show that the framework developed in the previous section can be used as an accurate analytical generative model for the non-uniform UE distributions where the UEs are clustered around their serving BSs. We first explain the simulation setup for this non-uniform UE distribution model and then describe a subtle difference in this model and the UE sampling framework developed in the previous section.

To simulate the non-uniform UE distribution model, start with a realization of a PPP Φ with density λ and form the Voronoi tessellation. Recall that in case of a cellular network, the Voronoi cell of each point denotes its coverage region in the nearest neighbor connectivity model. Distribute N_{μ} users uniformly in each Voronoi cell. For concreteness, we assume that N_u is the same for all the BSs and equal to the number of resource blocks, which models a full-buffer system. This assumption can be relaxed under certain conditions as discussed in [10]. Until this point, the UE distribution is fairly uniform although there is a subtle difference in this model and the way typical user is usually defined to be uniformly distributed over \mathbb{R}^2 . We will remark on this difference later in this section. To induce dependence in the BS and UE point processes, we again use the the thinning idea and retain points of the realization of Φ independently with probability p and remove the rest. The UEs corresponding to the points that are removed are also removed. The thinned version of the point process Φ with density λp models the BS locations. For the new coverage areas defined by the thinned point process, the remaining UEs are biased towards the cell interior as shown in Fig. 3. A favorable characteristic of this model is the probabilistic attraction introduced in the UE and BS point processes without inducing any geometric constraints. The coverage probability can now be numerically evaluated by averaging over these UE locations. Note that the result of Lemma 2 is not exact for this simulation model, as remarked below.

Remark 3 (UE uniformly distributed in \mathbb{R}^2 vs in randomly chosen Voronoi Cell). There is a subtle difference in performing downlink analysis at a typical UE uniformly distributed in \mathbb{R}^2 and uniformly distributed in a randomly chosen Voronoi cell. The former corresponds to the analytical model discussed in the previous section for p = 1 and the latter corresponds to the simulation model discussed in this section. The difference is induced by the structure of Poisson Voronoi tessellation and can be understood by a simple fact that a point uniformly distributed in \mathbb{R}^2 is more likely to fall in a bigger Voronoi cell, whereas there is no such bias when we choose a point uniformly distributed in a randomly chosen Voronoi cell.

We now compare the coverage probability of this nonuniform UE distribution model with the analytical expression derived in Lemma 2 in Fig. 4. We first note that the plots are surprisingly close and the difference highlighted in Remark 3 has a negligible impact on the coverage probability. Thus, the analytical model based on conditional thinning can be used as an accurate generative model to study coverage probability for this non-uniform UE distribution model described in this section. Further, we compare the coverage probability with the baseline model, where the UEs are distributed uniformly over \mathbb{R}^2 independent of the BS point process. We note that the difference in coverage predictions is significant even for high values of p. This clearly highlights the importance of accurate UE distribution models in the performance analysis of cellular networks.



Fig. 4. Comparison of the coverage probability of the proposed non-uniform UE distribution model with the analytical expression derived in Lemma 2 and the baseline model assuming uniform UE distribution ($\alpha = 4$).

V. CONCLUSION

In this letter, we addressed the problem of incorporating non-uniform UE distributions in the random spatial models for cellular networks. This work has numerous extensions, both in system modeling and analysis. In system modeling, it is important to develop empirical UE distribution models, especially for heterogeneous networks, where the UEs are more likely to be around low power nodes. In analysis, it is important to develop tractable modeling tools capable of handling correlations in the UE and BS point processes.

REFERENCES

- J. G. Andrews, F. Baccelli, and R. K. Ganti, "A tractable approach to coverage and rate in cellular networks," *IEEE Trans. on Communications*, vol. 59, no. 11, pp. 3122–3134, Nov. 2011.
- [2] H. S. Dhillon, R. K. Ganti, F. Baccelli, and J. G. Andrews, "Modeling and analysis of K-tier downlink heterogeneous cellular networks," *IEEE Journal on Sel. Areas in Communications*, vol. 30, no. 3, pp. 550 – 560, Apr. 2012.
- [3] S. Mukherjee, "Distribution of downlink SINR in heterogeneous cellular networks," *IEEE Journal on Sel. Areas in Communications*, vol. 30, no. 3, pp. 575 – 585, Apr. 2012.
- [4] R. Ganesh and K. Joseph, "Effect of non-uniform traffic distributions on performance of a cellular CDMA systems," in *Proc. IEEE Int. Conf. on* Universal Personal Communications, vol. 2, Oct. 1997, pp. 598 – 602.
- [5] A. L. Stolyar and H. Viswanathan, "Self-organizing dynamic fractional frequency reuse for best-effort traffic through distributed inter-cell coordination," in *Proc., IEEE INFOCOM*, Rio de Janeiro, Brazil, Apr. 2009, pp. 1287 – 1295.
- [6] D. Stoyan, W. S. Kendall, and J. Mecke, Stochastic Geometry and Its Applications, 2nd ed. Chichester: John Wiley and Sons, 1995.
- [7] F. Baccelli, P. Mühlethaler, and B. Blaszczyszyn, "Stochastic analysis of spatial and opportunistic Aloha," *IEEE Journal on Sel. Areas in Communications*, vol. 27, no. 7, pp. 1105 – 1119, Sep. 2009.
- [8] P. Madhusudhanan, J. G. Restrepo, Y. Liu, and T. X. Brown, "Carrier to interference ratio analysis for the shotgun cellular system," in *Proc.*, *IEEE Globecom*, Honolulu, Hawaii, Dec. 2009.
- [9] M. Haenggi, "On distances in uniformly random networks," *IEEE Trans.* on Info. Theory, vol. 51, no. 10, pp. 3584 – 3586, Oct. 2005.
- [10] H. S. Dhillon, R. K. Ganti, and J. G. Andrews, "Load-aware modeling and analysis of heterogeneous cellular networks," submitted to *IEEE Trans. on Wireless Communications*, Apr. 2012. Available Online: arxiv.org/abs/1204.1091.